NOTES:

1. SUBSTRATE: FUSED SILICA

2. COATING (APPLY ACROSS COATING APERTURE)

S1: RAVG >99% @ 600 - 950NM @ 5° AOI, P-POLARIZATION

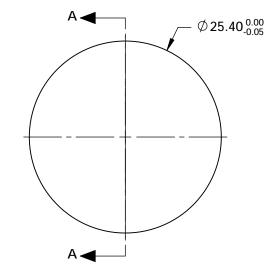
GDD SPECIFICATION:

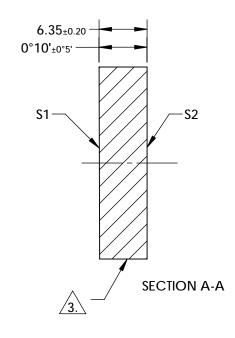
-50fs² @ 600 - 950NM @ 5° AOI, P-POLARIZATION

S2: NONE

3. FINE GRIND SURFACE

4. ROHS: COMPLIANT





FOR INFORMATION ONLY:
DO NOT MANUFACTURE
PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

	S1	S2]			Eamuna Optica	S®
SHAPE	PLANO	PLANO	THIRD ANGLE PROJECTION		TITLE	25.4mm Dia., 600 - 950nm, Complementary Chirped Mirror Pair	
IRREGULARITY	λ/10	N/A					
CLEAR APERTURE	Ø20.32	N/A				'	
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED	ALL DIMS IN	mm	DWG NO	17064	SHEET 1 OF 1